Electronic Acknowledgement Receipt					
EFS ID:	8801192				
Application Number:	10814482				
International Application Number:					
Confirmation Number:	6082				
Title of Invention:	Method for fabricating strained silicon-on-insulator structures and strained silicon-on insulator structures formed thereby				
First Named Inventor/Applicant Name:	Toshiharu Furukawa				
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Document Number	Document Description	File Name	File Size(Bytes)/ Message Digest	Multi Part /.zip	Pages (if appl.)
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3	Foreign Reference	JP2001144276A_EnglishAbstac	241593	no	1
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New International Application Filed with the USPTO as a Receiving Office

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